

**We are so pleased to announce the recipients of AM-FPD '09 Best Paper Award and AM-FPD '09 Student Paper Award. They will be presented the award in the Opening Session of AM-FPD '10 on July 5, 2010.**

**AM-FPD '09 Best Paper Award**

7-1

**Amorphous In-Ga-Zn-Oxide TFTs with Suppressed Variation for 4.0 inch QVGA AMOLED Display**

Hiroki Ohara, Toshinari Sasaki, Kousei Noda, Shunichi Ito, Miyuki Sasaki,  
Yayoi Toyosumi, Yuta Endo, Shuhei Yoshitomi, Junichiro Sakata,  
Tadashi Serikawa, Shunpei Yamazaki  
Semiconductor Energy Laboratory Co., Ltd, Japan

**AM-FPD '09 Student Paper Award**

**Soo-Yeon Lee, Seoul National University, Korea**

3-7 The Instability of Oxide-Based Thin Film Transistors Caused by the  
Negative Gate Bias Stress under the Light Illumination

**Mai Tani, Kochi National College of Technology, Japan**

6-2 Direct Patterning of Poly-Si Thin Films by Laser-Induced Backward  
Transfer

**Yudai Kamada, Kyoto University, Japan**

L-3 Photo Leakage Current of Zinc Oxide Thin Film Transistors in the Visible  
Light